



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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In re the Application of:

Bailey et al.

Serial No.: 09/452,691

Filed: 12/02/99

Docket No.: TI-27935

Examiner: Fenty,

Art Unit: 2815

For: AN INTEGRATED CIRCUIT HAVING A THIN FILM RESISTOR
LOCATED WITHIN A MULTILEVEL DIELECTRIC BETWEEN AN
UPPER AND LOWER METAL INTERCONNECT LAYER

COPY OF PAPERS
ORIGINALLY FILED

Amendment under 37 CFR 1.116

Assistant Commissioner of Patents
Washington, DC 20231

MAILING CERTIFICATE UNDER 37 C.F.R. §1.8(A)

I hereby certify that this correspondence is being deposited with
the U.S. Postal Service as First Class Mail in an envelope addressed
to: Assistant Commissioner for Patents, Washington, D.C. 20231 on

Jacqueline J. Garner, Reg. No. 36,144

Dear Sir:

The following amendments and remarks are offered in response to the
Examiner's Office Action dated 03/15/02. They are respectfully submitted as a
full and complete response to that Action.

Please amend the above-referenced application as follows:

In the Claims:

Please amend claim 1 as follows:

1. (amended) An integrated circuit comprising:

a lower metal interconnect layer located over a semiconductor body;

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